

IN THE ABSTRACT OF THE DISCLOSURE

Please amend the Abstract of Disclosure as follows:

An aluminum stabilization stacked body (~~101~~) formed by stacking a stabilization layer (~~103~~) formed with a metal and having a thickness of 0.001-1 μm with any of a sputtering method, a deposition method and an ion plating method on a whole surface of a thin film (~~102~~) having a surface formed with aluminum.